

IN THE CLAIMS

Please amend Claim 6 as shown in marked-up form as follows:

1. (Previously Amended) A stamp (10) for use in a lithographic process, which stamp (10) comprises a stamp body (5) with a printing face (3), said stamp body (5) having a first recess (11) with an aperture (15) in the printing face (3), wherein the first recess (11) becomes narrower as its distance to the printing face (3) increases, and

cross-sections of the first recess (11) parallel to the printing face (3), when projected perpendicularly on the printing face (3), lie within the aperture (15), and a third recess (13) with an aperture (17) in the printing face (3) is present in the stamp body (5),

which recess (13) has cross-sections parallel to the printing face (3) and becomes substantially narrower as its distance to the printing face (3) increases, said cross-sections, when projected perpendicularly on the printing face (3), lying within the aperture (17),

the aperture (17) of the third recess (13) and the aperture (15) of the first recess (11) each have a dimension in a first direction in the printing face (3), and

said dimension of the aperture (17) of the third recess (13) is at least five times the dimension of said aperture (15) of the first recess (11).

2. (Original) A stamp (10) as claimed in claim 1, characterized in that the first recess (11) has a triangular shape in a first plane perpendicular to the printing face (3).

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3. (Original) A stamp (10) as claimed in Claim 1, characterized in that

a second recess (12) with an opening (16) in the printing face (3) is present in the stamp body (5),

which second recess (12) has cross-sections parallel to the printing face (3) and becomes narrower as its distance to the printing face (3) increases, said cross-sections, when projected perpendicularly on the printing face (3), lie within the aperture (16), and

said aperture (16) is present at a distance smaller than 1 μm from the aperture (15) of the first recess (11).

4. (Previously Withdrawn)

5. (Previously Amended) A stamp (10) as claimed in claim 1, characterized in that said dimension of the aperture (17) of the

third recess (13) is at least twenty times said dimension of the aperture (15) of the first recess (11).

6. (Amended) A method of manufacturing a stamp (10) for use in a lithographic process, which stamp (10, 110) has a stamp body (5, 105) with a surface (4, 104) which coincides partly with the printing face (3, 103), comprising the steps of:

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anisotropic etching of a surface (27) of a mold (20) into a patterned mold surface (29), such that a first recess (21) and a second recess (23) are created in the mold (20) with apertures in the original surface (27), which first recess (21) and a second recess (23) become narrower as its distance to the original surface (27) increases and has cross-sections parallel to the original surface (27) which, when projected perpendicularly on the original surface (27), lie within the aperture (41), and wherein the first and second recesses have different apertures, and

making a replica of the patterned mold surface (29) in a first body (105) with a patterned surface (104), wherein the replica contains structures of different sizes.

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7. (Original) A method as claimed in claim 6, characterized in that a replica is made of the patterned surface (104) of the first body (105) in a second body (5) which has a patterned surface (4).

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8-10 (Previously Withdrawn)

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